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APPLICATION NO. FILING DATE FIRST NAMED INVENTOR ATTORNEY DOCKET NO. CONFIRMATION NO. 10/045,036 01/15/2002 Toshihiko Tanaka XA-9613 2902 181 EXAMINER 7590 11/26/2004 MILES & STOCKBRIDGE PC PHAN, THIEM D 1751 PINNACLE DRIVE ART UNIT PAPER NUMBER SUITE 500 MCLEAN, VA 22102-3833 3729

DATE MAILED: 11/26/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

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Office Action Summary	Application No.	Applicant(s)	7	
	10/045,036	TANAKA ET AL.		
	Examiner	Art Unit		
	Tim Phan	3729	<u> </u>	
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply				
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).  Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).				
Status				
1) Responsive to communication(s) filed on 20 Se	eptember 2004.			
<u> </u>	2a) ☐ This action is <b>FINAL</b> . 2b) ☑ This action is non-final.			
3) Since this application is in condition for allowance except for formal matters, prosecution as to the ments is				
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.				
Disposition of Claims				
4) Claim(s) 1-8 and 18-22 is/are pending in the ap 4a) Of the above claim(s) is/are withdraw 5) Claim(s) is/are allowed. 6) Claim(s) 1-8 and 18-22 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or	vn from consideration.			
Application Papers				
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) access applicant may not request that any objection to the Replacement drawing sheet(s) including the correct and the contract of the contract	epted or b) objected to by the bedrewing(s) be held in abeyance. See ion is required if the drawing(s) is obj	e 37 CFR 1.85(a). jected to. See 37 CFR		
Priority under 35 U.S.C. § 119				
<ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No.</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>				
Attachment(s)				
1) Notice of References Cited (PTO-892)	4) Interview Summary			
Notice of Draftsperson's Patent Drawing Review (PTO-948)     Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)     Paper No(s)/Mail Date	Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:		52)	

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#### **DETAILED ACTION**

1. The amendment filed on 09/20/04 has been fully considered and made of record.

### Specification

2. On page 1, before "BACKGROUND OF THE INVENTION", insert:

"CROSS REFERENCE TO RELATED DOCUMENT

This application claims the benefit of Japanese Patent Applications No. 2001-019774, filed on 1/29/01.".

## Claim Rejections - 35 USC § 101

3. 35 U.S.C. 101 reads as follows:

Whoever invents or discovers any new and useful process, machine, manufacture, or composition of matter, or any new and useful improvement thereof, may obtain a patent therefor, subject to the conditions and requirements of this title.

4. Claims 1-8 and 18-22 are rejected under 35 U.S.C. 101 because the claimed invention is not supported by either a credible asserted utility or a well established utility.

The Applicants' claimed invention of fabricating photomasks of shade pattern at nano size levels on a glass surface will have the effect of scattering light beams due to *Fresnel* 

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Diffraction and furthermore the prior art, Hatakeyama et al (USPN 6,007,969 hereinafter '969), teaches that photolithography by the microfabrication technique of photomasks in the range of nanometers is not practical (Cf. The '969, Col. 1, lines 49 ff.) and virtually impossible.

Claims 1-8 and 18-22 are also rejected under 35 U.S.C. 112, first paragraph. Specifically, since the claimed invention is not supported by either a credible asserted utility or a well established utility for the reasons set forth above, one skilled in the art clearly would not know how to use the claimed invention.

#### Response to Arguments

5. Applicants' arguments filed 9/20/04 have been fully considered but they are not persuasive for the following reasons:

Applicants recite: "... independent Claim 1 has been amended ... projection exposure treatment in which exposure light from the photomask ... shade pattern ... nano particles ..." (Cf. claim1, lines 4-8; Remaks, page 5, 3<sup>rd</sup> paragraph). The Patent Office's position is that since the prior art '969 teaches that photolithography by the microfabrication technique of photomasks in the range of nanometers is virtually impossible (Cf. The '969, Col. 1, lines 49 ff.).

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### Conclusion

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tim Phan whose telephone number is 571-272-4568. The examiner can normally be reached on M - F, 9AM - 5PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Peter Vo can be reached on 571-272-4690. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

TP

CARL J. ARBES
PRIMARY EXAMINER

Tim Phan Examiner Art Unit 3729

tp November 19, 2004